| L Niumber | Hits | Search Text  | DB                | Time stamp       |
|-----------|------|--|-------------------|------------------|
| L Number  | 8392 | inspect\$ adj6 (mask or masks or wafer or wafers)                | USPAT;            | 2003/12/04 13:17 |
| 1         | 6392 | Inspects adjo (mask of master of water of water)                 | US-PGPUB;         |                  |
|           |      |  | EPO; JPO;         |                  |
|           |      |  | DERWENT;          |                  |
|           |      |  | IBM_TDB           |                  |
| 1         | 916  | (pulsed adj3 laser) near12 (uv or ultraviolet)                   | USPAT;            | 2003/12/04 13:15 |
| 2         | 910  | (puised days lasery float 22 (at a same )                        | US-PGPUB;         |                  |
|           |      |  | EPO; JPO;         |                  |
|           |      |  | DERWENT;          |                  |
|           |      |  | IBM_TDB           |                  |
|           | 14   | (inspect\$ adj6 (mask or masks or wafer or wafers)) and          | USPAT;            | 2003/12/04 13:16 |
| 3         | - 1  | ((pulsed adj3 laser) near12 (uv or ultraviolet))                 | US-PGPUB;         |                  |
|           |      | ((pulsed days tassify the same )                                 | EPO; JPO;         |                  |
|           |      |  | DERWENT;          |                  |
|           |      |  | IBM_TDB           | 2002/42/04 42:47 |
| 4         | 9291 | inspect\$ adj6 (mask or masks or wafer or wafers or              | USPAT;            | 2003/12/04 13:17 |
| 1         | 3231 | photomasks or reticle or reticles)                               | US-PGPUB;         |                  |
|           |      |  | EPO; JPO;         |                  |
|           |      |  | DERWENT;          |                  |
|           |      |  | IBM_TDB           | 2003/12/04 13:24 |
| 5         | 14   | ((pulsed adj3 laser) near12 (uv or ultraviolet)) and (inspect\$  | USPAT;            | 2003/12/04 13.24 |
|           |      | adj6 (mask or masks or wafer or wafers or photomasks or          | US-PGPUB;         |                  |
|           |      | reticle or reticles))  | EPO; JPO;         |                  |
|           |      |  | DERWENT;          |                  |
|           |      |  | IBM_TDB<br>USPAT; | 2003/12/04 13:25 |
| 6         | 29   | (inspect\$ adj6 (mask or masks or wafer or wafers or             | US-PGPUB;         | 2003/12/01 13:20 |
|           |      | photomasks or reticle or reticles)) and (rotat\$ near4 diffus\$) | EPO; JPO;         |                  |
|           |      |  | DERWENT;          |                  |
|           |      |  | IBM_TDB           |                  |
|           |      |  | םטו_ויוטו         |                  |